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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/649,472	08/27/2003	1765	750	TS00-485B	6	8	1

*George O. Saile
28 Davis Avenue
Poughkeepsie, NY 12603

CONFIRMATION NO. 5371

FILING RECEIPT



OC000000011382815

Date Mailed: 12/01/2003

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Juing-Yi Cheng, Chi Shange Town, TAIWAN;
Kevin Su, Jubei City, TAIWAN;

Assignment For Published Patent Application

TAIWAN SEMICONDUCTOR MANUFACTURING COMPANY;

Domestic Priority data as claimed by applicant

This application is a DIV of 09/981,436 10/18/2001 PAT 6,638,866

Foreign Applications

If Required, Foreign Filing License Granted: 11/29/2003

Projected Publication Date: 03/11/2004

Non-Publication Request: No

Early Publication Request: No

Title

Novel chemical-mechanical polishing (CMP) process for shallow trench isolation

**LICENSE FOR FOREIGN FILING UNDER
Title 35, United States Code, Section 184
Title 37, Code of Federal Regulations, 5.11 & 5.15**

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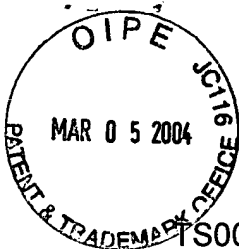
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GEORGE O. SAILE & ASSOCIATES
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March 3, 2004

To: Mail Stop: Application Number
Commissioner For Patents
P.O. Box 1450
Alexandria, VA 22313-1450

From: Stephen B. Ackerman

Subject: Serial No.: 10/649,472
Filing Date: 08/27/03
Inventor: J. Y. Cheng, et al
Title: Novel Chemical-Mechanical Polishing (CMP) Process for
Shallow Trench Isolation

REQUEST TO CORRECT FILING RECEIPT

Dear Sir:

On the copy of the enclosed Filing Receipt, the Attorney Docket Number is incorrect. The correct Attorney Docket Number is **TS00-484B**.

Please make the necessary change to correct the error on the Filing Receipt.

If there are any questions, please contact the undersigned attorney at (845) 452-5863. Thank you for your attention to this matter.

Respectfully Submitted,

Stephen B. Ackerman, Reg. No. 37,761